

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0



Title of
Invention

Sacrificial Surfactanated Pre-Wet for Defect Reduction in a
Semi-Conductor Photolithography Developing Process

Application Number: 10/675419



Confirmation Number: 6182

First Named Applicant: John Kulp

Attorney Docket Number: CT-001

Search string: (6117486 or 6132940 or 6147010 or 6159662
or 6402398 or 6420101).pn.

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
<input checked="" type="checkbox"/>	1	6117486	2000-09-12	Yoshihara		427	240
<input checked="" type="checkbox"/>	2	6132940	2000-10-17	Mih et al.		430	394
<input checked="" type="checkbox"/>	3	6147010	2000-11-14	Whitman		438	782
<input checked="" type="checkbox"/>	4	6159662	2000-12-12	Chen et al.		430	313
<input checked="" type="checkbox"/>	5	6402398	2002-06-11	Szajewski et al.	B1	396	604
<input checked="" type="checkbox"/>	6	6420101	2002-07-16	Lu et al.	B1	430	326

Remarks

Note: Remarks are not for responding to an office action.

Applicants are of the opinion that no fee is due as a result of this Information Disclosure Statement. If any charges or credits are necessary to complete this communication, please apply them to Deposit Account No. 23-3000.

Signature

Examiner Name	Date
<i>John Kulp</i>	02/14/06

SUBSTITUTE FORM PTO-1449
(MODIFIED)U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.
CT-001SERIAL NO.
10/675,419INFORMATION DISCLOSURE
STATEMENT BY APPLICANT

(Use several sheets if necessary)

APPLICANT
John M. KulpFILING DATE
September 30, 2003GROUP
1756

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MD	A.A	5	8	4	5	1	7	0	12/01/1998	Ogata	396	604	08/15/1997
MD	A.B	6	1	3	6	5	1	4	10/24/2000	Phan et al.	430	327	01/31/2000
MD	A.C	6	4	7	2	1	2	7	10/29/2002	Takizawa	430	322	07/12/2000
	A.D												
	A.E												
	A.F												
	A.G												
	A.H												
	A.I												
	A.J												
	A.K												

FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS

		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
MD	A.L	WO 01/63365	08/30/2001	PCT	G03F	7/32	
	A.M						
	A.N						
	A.O						
	A.P						
	A.Q						

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)

	A.R	
	A.S	
	A.T	

EXAMINER

Deborah Chalut Davis

DATE CONSIDERED

02/14/06

EXAMINER: Initial if citation considered, whether or not in conformance. Draw line through citation only if not in conformance and not considered.
Include a copy of this form with next communication to Applicant.